



Tutorial 1 : Oxide Thin Film Transistor

AM Chair W. S. Choi (Hoseo Univ., Korea)

T1-1 09:30~10:30

Doping, Defects, and Hydrogen in Oxide Semiconductors in Oxide Semiconductors

K. J. Chang (KAIST, Korea)

Coffee Break 10:30~10:40

T1-2 10:40~11:40

Oxide Thin Film Transistor

Y. S. Park (SAIT, Korea)

Lunch 11:40~13:10

PM Chair W. J. Lee (Samsung Electronics Co., Ltd., Korea)

T1-3 13:10~14:10

Current Research Issues in Oxide TFTs

C.-S. Hwang (ETRI, Korea)

T1-4 14:10~15:10

Application of Oxide TFT to Display

J.-H. Lee (Samsung Electronics Co., Ltd., Korea)

Coffee Break 15:10~15:30

T1-5 15:30~16:30

Solution-Processed Oxide Thin Film Transistor

H. J. Kim (Yonsei Univ., Korea)